## Aerosol-assisted route to Low-E transparent conductive gallium-doped zinc oxide coatings from pre-organized and halogen-free precursor.

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d(TGA)/dt ----DSC TGA (%) d(TGA)/dt ---- DSC TGA (%) 385 °C DSC (mW/mg) 258 °C DSC (mW/mg) Mass (%) Mass (%) 105 °C 94 °C 386 °C 400 450 Temperature (°C) Temperature (°C)

## **ELECTRONIC SUPPORTING INFORMATION**

**Figure S1.** TGA(green)/DSC(blue) of precursor [EtZnO<sup>i</sup>Pr]<sub>4</sub> under helium (left) and air (right). The red line represents the 1<sup>st</sup> derivative of the mass with time.



**Figure S2.** XPS scans of Ga 2p peaks of ZnO (S0) and GZO (S1-S5) thin films with increasing amounts of at% Ga. Vertical black lines indicate the literature value of Ga  $2p_{3/2}$  for Ga<sup>3+</sup> in Ga<sub>2</sub>O<sub>3</sub> environment and vertical red lines indicate the literature value of Ga  $2p_{3/2}$  for Ga<sup>0</sup> (metal).<sup>[1]</sup>



**Figure S3.** XPS scans of Ga 3d peaks of ZnO (S0) and GZO (S1-S5) thin films with increasing amounts of at% Ga. Vertical black lines indicate the literature value of Ga  $3d_{5/2}$  for Ga<sup>3+</sup> in Ga<sub>2</sub>O<sub>3</sub> environment<sup>[2]</sup> (blue rectangle shows error of 0.2 eV) and vertical red lines indicate the literature value of Ga  $3d_{3/2}$  for Ga<sup>0</sup> (metal).<sup>[1]</sup>

Equation S1. Equation used to calculate the texture coefficient for each plane

 $TC(hkl) = [I(hkl)/I_0(hkl)] / [(1/N)^* [I(hkl)/I_0(hkl)]]$ 



Figure S4. Texture coefficients for ZnO and GZO films with 0.7 – 7.0 at% Ga.



**Figure S5.** Optical transmission and reflection spectra of undoped ZnO (S0) and gallium-doped ZnO thin films with increasing at% of Ga (S1 – S5).



**Figure S6.** Relationship between carrier concentration (N<sub>b</sub>) and band gap enhancement of GZO, in comparison with total amounts of gallium incorporated as dopant (at% Ga x  $\eta_{DE}$ ) for each level of at% Ga.



**Figure S7.** Representation of  $E_g$  vs  $N_b^{2/3}$  for thin films S0 – S5.



**Figure S8.** Representation of effective mass  $m^*/m_0$  vs. N<sub>b</sub><sup>2/3</sup> for thin films S0 – S5.



Figure S9. <sup>1</sup>H NMR of precursor  $[EtZnO'Pr]_4$  in  $C_6D_6$ .





Figure S11. FTIR of precursor [EtZnO<sup>i</sup>Pr]<sub>4</sub>.



Figure S12. FTIR of hydrolysed precursor [EtZnO<sup>i</sup>Pr]<sub>4</sub>.